

FORM PTO-1449  
(Rev. 2-32)U.S. Department of Commerce  
Patent and Trademark Office

Atty. Docket No.

05-583

Serial No.

10/541,970

INFORMATION DISCLOSURE  
STATEMENT BY APPLICANT

(Use several sheets if necessary)

Applicant:

Gicquel, et al.

Filing Date:

July 11, 2005

Group:

TBD

## U.S. PATENT DOCUMENTS

Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date if Appropriate
KMS	1.	6,200,183 B1	March 13, 2001	Badzian, et al.	445	24	
KMS	2.	6,261,424 B1	July 17, 2001	Goncharenko, et al.	204	192.38	

## FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation Yes	No
KMS	3.	0 582 397 A2	July 16, 1993	EP				
KMS	4.	0 635 584 A1	July 14, 1994	EP				
KMS	5.	WO 01/96633 A1	June 14, 2001	PCT				
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## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc).

KMS	7.	Gicquel, et al., <i>Journal of Applied Physics</i> , June 15, 1998, Vol. 83, No. 12, pp. 7504-7521.
KMS	8.	Gicquel, et al., <i>Materials Research</i> , 2003, Vol. 6, No. 1 pp. 25-37.
KMS	9.	Gordon, et al., <i>Journal of Applied Physics</i> , February 1, 2001, Vol. 89, No. 3, pp. 1544-1549.
KMS	10.	Hassouni, et al., <i>Plasma Sources Science and Technology</i> , 2001, Vol. 10, pp. 61-75.
KMS	11.	Lombardi, et al., <i>Journal of the Electrochemical Society</i> , 2003, Vol. 150, No. 5, pp. C311-C319.
KMS	12.	Lombardi, et al., "Diagnostics and Modeling of Moderate Pressure Microwave H <sub>2</sub> /CH <sub>4</sub> Plasmas Obtained Under Pulsed Mode" paper, 2001.
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EXAMINER /Kelly Stouffer/

DATE CONSIDERED 07/28/2006

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication.